

LIST OF PATENTS AND OTHER ITEMS FOR APPLICANT'S  
INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

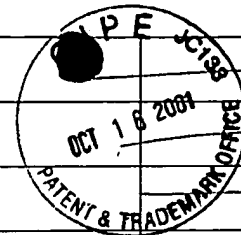
APPLICANT:  
Eric J. BergmanFILING DATE:  
March 19, 2001

GROUP: 1746

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE
ZE	AA	3,898,141	8/5/75	Ermanis et al.			
	AB	4,050,954	9/27/77	Basi			
	AC	4,261,791	4/14/81	Shwartzman			
	AD	4,264,374	4/28/81	Beyer et al.			
	AE	4,615,762	10/7/86	Jastrzebski			
	AF	4,899,767	2/13/90	McConnell			
	AG	4,943,540	7/24/90	Ren et al.			
	AH	4,971,654	11/20/90	Schnegg et al.			
	AI	5,181,985	1/26/93	Lampert et al.			
	AJ	5,221,423	6/22/93	Sugino et al.			
	AK	5,294,570	3/15/94	Fleming Jr. et al.			
	AL	5,464,480	11/7/95	Matthews			
	AM	5,489,557	2/6/96	Jolley			
	AN	5,232,511	8/3/93	Bergman			
	AO	5,158,100	10/27/92	Tanaka et al.			
	AP	5,235,995	8/17/93	Bergman et al.			
	AQ	5,238,500	8/24/93	Bergman			
	AR	5,129,955	7/14/92	Tanaka			
	AS	5,950,643	9/14/99	Miyazaki et al.			
	AT	6,146,469	11/14/00	Toshima			
	AU	4,917,123	4/17/90	McConnell et al.			
	AV	5,105,556	4/21/92	Kurokawa et al.			
	AW	5,326,406	7/5/94	Kaneko et al.			
ZE	AX	4,186,032	1/29/80	Ham			

ZE	AY	4,749,440	6/7/88	Blackwood et al.			
	AZ	4,817,652	4/4/89	Liu et al.			
	BA	5,832,177	11/3/98	Shinagawa et al.			
	BB	5,964,952	10/12/99	Kunze-Concewitz			
	BC	5,503,708	4/2/96	Koizumi et al.			
ZE	BD	5,378,317	1/3/95	Kashiwase et al.			



### FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
							YES	NO
ZE	BE	JP 05-902329	4/9/93	Japan				
	BF	JP 03-208900	9/12/91	Japan				
	BG	JP 02-164035	6/25/90	Japan				
	BH	JP 08-160032	6/21/96	Japan				
	BI	JP 08-08222	1/12/96	Japan				
	BJ	JP 62-117330	5/28/87	Japan				
	BK	JP 05-047741	2/26/93	Japan				
	BL	JP 04-326516	11/16/92	Japan				
	BM	JP 62 118528	5/29/87	Japan				
	BN	JP 05-183151	7/23/93	Japan				
	BO	0 472 441	8/1991	Europe				
	BP	0 548 596	11/30/92	Europe				
	BQ	0 587 889	5/13/92	Europe				
ZE	BR	JP 04 301245	10/26/92	Japan				

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### OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

ZE	BS	/	"Gas Phase Etching of Silicon Oxide With Anhydrous HF and Isopropanol", Proc. Electchem Co. (1994); Butterbaugh
ZE	BT	/	"Particle Deposition and Removal in Wet Cleaning Processes for ULSI Manufacturing", Mitsushi Itano et al, IEEE Transactions on Semiconductor Manufacturing, Vol. 5, No. May 1992, pp. 114-120.
ZE	BU	/	"Low Temperature Cleaning of HF-Passivated Si(111) Surface with VUV Light", Yuji Takakuwa et al., Japanese Journal of Applied Physics, 28 (1989) July, Part 2, Tokyo, JP, pp. 1274-1277

EXAMINER:

EL-Arini

Examiner

DATE CONSIDERED:

11/20/01

EXAMINER: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include a copy of this form with next communication to applicant